

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Toru KIMURA <i>et al.</i>	Confirmation No.: 4887
Application No.: 10/586,187	Examiner: Johnson, Connie P.
Filed: July 31, 2007	Group Art Unit: 1722

For: UPPER LAYER FILM FORMING COMPOSITION FOR LIQUID IMMERSION  
AND METHOD OF FORMING PHOTORESIST PATTERN

Commissioner for Patents  
Alexandria, VA 22313-1450

**AMENDMENT UNDER 37 C.F.R. § 1.111**

Dear Sir:

The following Amendment and Remarks are submitted in response to the Office Action dated January 5, 2011.

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